

Electronic Patent Application Fee Transmittal

Application Number:	10522036			
Filing Date:	19-Jan-2005			
Title of Invention:	Chemically amplified positive photo resist composition and method for forming resist pattern			
First Named Inventor/Applicant Name:	Kenji Maruyama			
Filer:	Neil S. Bartfeld/L. Racquel Raymond			
Attorney Docket Number:	SHIGA7.004APC			
Filed as Large Entity				
U.S. National Stage under 35 USC 371 Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Submission- Information Disclosure Stmt	1806	1	180	180
Total in USD (\$)				180